Supplementary Information

Boost quantum efficiency of BiVO₄ photoanode by increasing oxygen vacancies for highly-efficient solar water oxidation

Bin Li, ^{a, b} Qi Qin, ^a Chuanyong Jian, ^{a, b} Qian Cai, ^a and Wei Liu ^{a*}

^a CAS Key Laboratory of Design and Assembly of Functional Nanostructures, Fujian Institute of Research on the Structure of Matter, Chinese Academy of Sciences, Fuzhou, Fujian, 350002, China

^b University of Chinese Academy of Sciences, Beijing, 100049, China

*Corresponding authors: E-mail: liuw@fjirsm.ac.cn

Experimental section

Photoelectrochemical measurements:

Photocurrent-potential curves were monitored using linear sweep voltammogram in a voltage window of 0.2~1.3 V vs. RHE with a scan rate of 10 mV/s. The conversion between potentials vs. Ag/AgCl and RHE is performed according to the Nernst equation below: [1]

$$E_{RHE} = E_{Ag/AgCl} + 0.059 \text{*pH} + E_{Ag/AgCl}^{0}$$

Where E_{RHE} is the potential referred to a reversible hydrogen electrode (RHE), and $E_{Ag/AgCl}$ is the measured potential against Ag/AgCl reference electrode. The incident-photon-to-current-efficiency (IPCE) as a function of wavelength for the prepared photoanodes was measured at a bias of 1.23 V vs. RHE by a CHI660e electrochemical workstation, and the monochromator was incremented in the spectral range (300-600

nm) with a sampling interval of 20 nm and a current sampling time of 10s. The IPCE was calculated by equation: [2]

IPCE (%) =
$$\frac{1240 \times J_{ph}}{P_{mono} \times \lambda} \times 100\%$$

Where J_{ph} presents the photocurrent density (mW·cm⁻²) obtained from the electrochemical workstation. P_{mono} is the intensity of the incident monochromatic light (mW·cm⁻²), and λ is the wavelength (nm) of the monochromatic light.

Applied bias photon-to-current efficiency (ABPE) can be calculated using the following equation: [2]

ABPE (%) =
$$\frac{(1.23 - V_b) \times J_{ph}}{P_{light}} \times 100\%$$

Where J_{ph} presents the photocurrent density (mW·cm⁻²) obtained from the electrochemical workstation. V_b refers to the applied bias vs. RHE (V), and P_{total} is the total light intensity of AM 1.5 G (100 mV· cm⁻²).

To confirm the inference, we calculated the transient decay time using the following equation: [3]

$$D = \frac{I_t - I_s}{I_m - I_s}$$

Where I_t represents current at time t, I_s represents the stabilized current, and I_m represents the current spike. The transient decay time can be defined as the time at which $\operatorname{Ln} D = -1$.

Chopped-light amperometric J-t measurements were performed at an applied potential of 1.23 V under chopped light irradiation (light on or off cycles: 10 s). Mott-Schottky (MS) spectra were measured in the dark (increment: 10 mV, open circles:

1000 Hz, filled circles: 500 Hz). Electrochemical impedance spectroscopy (EIS) measurements for all the photoanodes were conducted by applying AC voltage amplitude of 10 mV within the frequency range from 10^5 to 10^{-2} Hz.

Solid current-voltage (I-V) measurements: Solid-state conductivity measurements were carried out by a 2-point measurement setup which consisted of a USMCO micromanipulator and precision semiconductor parameter analyzer (4156C, Agilent technologies, Japan). All I-V curves were measured with 20 mV/s sweep rate in the voltage window from -300 mV to 300 mV.

The charge carrier density (N_d) can be calculated using the following equation: [4]

$$N_d = \frac{2}{e\varepsilon\varepsilon_o} \times \left[\frac{d\left[\frac{1}{C^2}\right]}{dV_s}\right]^{-1}$$

The electronic charge is 1.6×10^{-19} C, vacuum permittivity (ε_0) is 8.86×10^{-12} F • m⁻¹, and relative permittivity (ε) is 68 for BiVO₄ photoanode. V_s (V) is the applied potential for MS curves. C (F • cm⁻²) is the space charge capacitance in the semiconductor obtained from MS curves.



Fig. S1 Schematic of the fabrication process flow of BiVO₄ films.



Fig. S2 Top view SEM images of three different $(BiO)_2CO_3$ films. It can be clearly seen that the $(BiO)_2CO_3$ particle size is around 1 μ m.



Fig. S3 Top view SEM images of Bi_2O_3 films after annealing the $(BiO)_2CO_3$ films in air at different temperature in the range from 250 °C to 350 °C.



Fig. S4 Top view SEM images of BiVO₄ films.



Fig. S5 Photocurrent density vs. applied potential curves of the BVO-2 films of (a) different annealing times, (b) calcination tempe rature in air under back illumination through an AM 1.5 G filter with the intensity of 100 mW \cdot cm⁻² in 1 M potassium electrolyte with 0.2 M Na₂SO₃.



Fig. S6 I_s plots under AM 1.5 G illumination of the BVO-2 films annealed by different time and temperature. All measurements were taken in 1 M potassium borate electrolyte with 0.2 M Na₂SO₃.



Fig. S7 Fluorescence probe measurement of O_2 and H_2 generation from a BVO-2 electrode at 1.23 V vs RHE under AM 1.5G, 100 mW/cm² illumination



Fig. S8 Depth-profile XPS of different BVO-1.

Table

Catalyst	Electrolyte	pН	J ^[a]	Reference
			(mA·cm ⁻²)	
BiVO ₄	1 M KB	2.44	4.36	This work
BiVO ₄	1 M KB	2.38	5.5	Adv. Mater. 2018,1800486
BiVO ₄	0.5 M KPi	1.5	4.8	Science. 2014,343,990.
BiVO ₄	0.1 M	/	2.75	Adv. Energy Mater. 201802198.
	$K_2B_4O_7$ ·4H ₂ O			
Mo: BiVO ₄	0.5 M KB	~1.2	~2.7	Energy Lett. 2018, 3, 1648.
BiVO ₄	1 M KB	0.75	2	Energy Lett. 2017, 2, 1062.
BiVO ₄	1 M KB	2.5	3.4	Angew. 201703491.
BiVO ₄	0.4 M KPi	~1.5	/	ACS Catal.2017, 7, 1868.
BiVO ₄	0.1 M KPi	~1	~2	Angew. 2016, 55, 1769.
Sb-Doped	1 M KB	/	1.6	Nano lett. 2016, 16, 3463.
SnO ₂ /BiVO ₄				
Core/Shell				
Co ₃ O ₄ / BiVO ₄	0.5 M KPi	~0.6	~3.4	J. Am. Chem. Soc. 2015, 137,
				8356.
BiVO ₄	0.5 M Na ₂ SO ₄	1.5	/	Nano. 2014, 8, 7088.
BiVO ₄	0.1 M	~0.2	~2	J. Am. Chem. Soc. 2012, 134,
	KH ₂ PO ₄			2186.
BiVO ₄	natural	0.5	/	Energ.Environ.Sci. 2011, 4, 4046
	seawater			
Mo: BiVO ₄	0.5 M Na ₂ SO ₄	1	/	Energ.Environ.Sci. 2011, 4, 5028
WO ₃ /BiVO ₄	0.5 M Na ₂ SO ₄	~1.6	/	Nano lett. 2011, 11, 1928
W: BiVO ₄	0.1 M KPi	1	~1.6	J. Am. Chem. Soc. 2011, 133,
				18370.
BiVO ₄	natural	0.5	/	Energ.Environ.Sci. 2011, 4, 4046.
	seawater			

Table S1. PEC performance comparison of BiVO₄ anodes reported in literature.

[a] refers the current density produced at 1.23 V vs RHE with sacrificial reagent

Reference

- [1] L. Zhang, E. Reisner, J. Baumberg, Energy Environ. Sci., 2014, 7, 1402-1408.
- [2] Z. Chen, T. F. Jaramillo, T. G. Deutsch, A. Kleiman-Shwarsctein, A. J. Forman, N.Gaillard, R. Garland, K. Takanabe, C. Heske, M. Sunkara, E. W. McFarland, K.Domen, E. L. Miller, J. A. Turner, H. N. Dinh, *J. Mater. Res.*, 2010, 25, 3-16.
- [3] J. M. Wu, Y. Chen, L. Pan, P. Wang, Y. Cui, D. Kong, L. Wang, X. Zhang, J. Zou, Appl. Catal. B Environ., 2018, 221, 187-195.
- [4] M. Ye, J. Gong, Y. Lai, C. Lin, Z. Lin, J. Am. Chem. Soc., 2012, 134, 15720-15723.